

Broken-gap Energy Alignment in Two-dimensional van der Waals Heterostructures for Multifunctional Tunnel Diodes

Patrick David Taylor,^a Sherif Abdulkader Tawfik^b and Michelle J.S. Spencer^{*a}

^a*School of Science, RMIT University, GPO Box 2476, Melbourne, Victoria, 3001, Australia.*

^b*Applied Artificial Intelligence Institute, Deakin University, Victoria, Australia*

*E-mail: michelle.spencer@rmit.edu.au

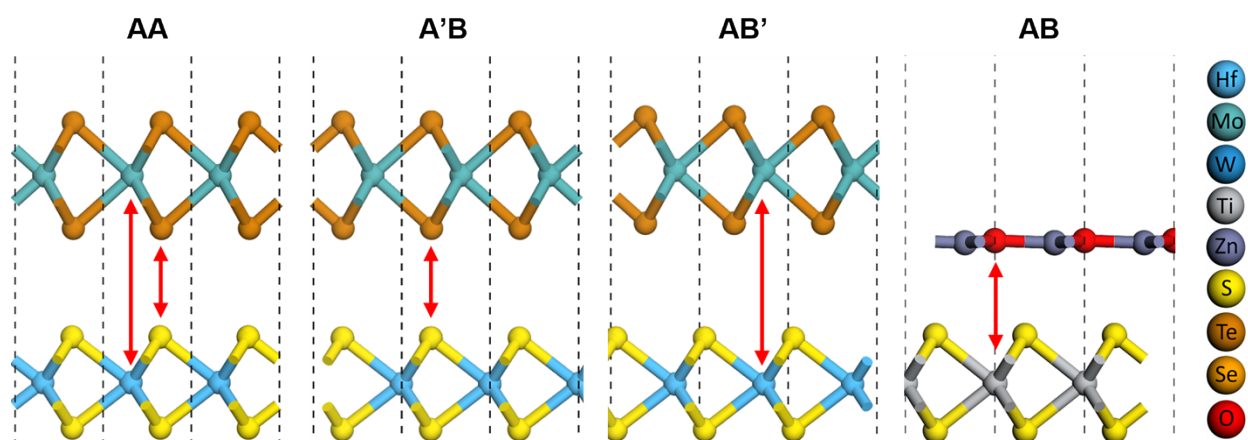


Figure S1. The 3 high symmetry stacking patterns, AA, A'B and AB', considered for HfS₂/MoTe₂, HfS₂/WTe₂, TiS₂/WSe₂ and TiSe₂/WTe₂, and AA, AB' and AB, considered for 1T-HfS₂/WTe₂ and TiS₂/ZnO.

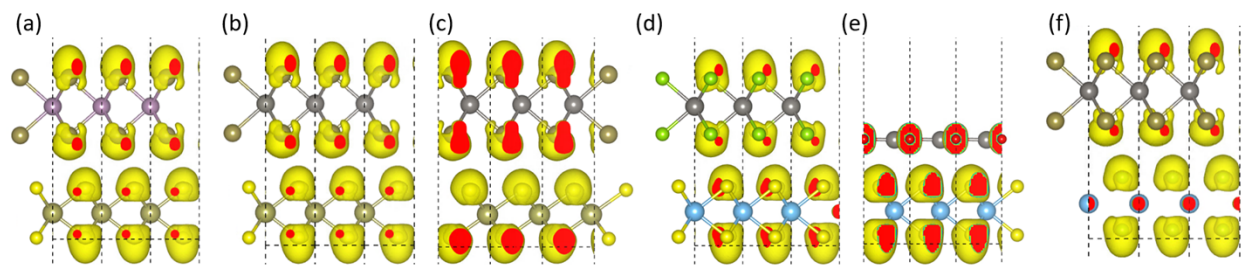


Figure S2. Electron localisation function isosurface plots of (a) $\text{HfS}_2/\text{MoTe}_2$, (b) $\text{HfS}_2/\text{WTe}_2$, (c) 1T- $\text{HfS}_2/\text{WTe}_2$, (d) $\text{TiS}_2/\text{WSe}_2$, (e) TiS_2/ZnO and (f) $\text{TiSe}_2/\text{WTe}_2$.

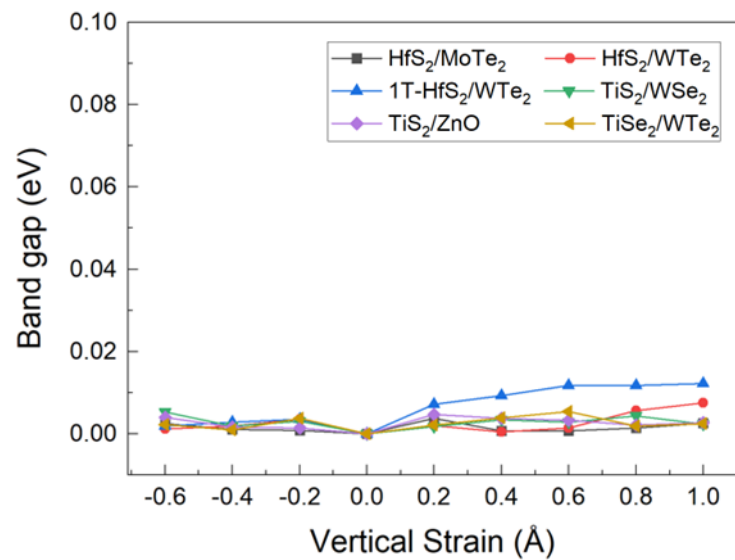


Figure S3. Calculated band gap as a function of vertical strain for the 6 heterostructures.